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IFW

TS02-1079

May 28, 2004

To: Commissioner for Patents
Office of Initial Patent Examination
Customer Service Center
P.O. Box 1450
Alexandria, VA 22313-1450

From: Stephen B. Ackerman

Subject: Serial No.: 10/666,354
Filing Date: 09/19/03
Inventor: H. L. Chang, et al
Title: Two Step Post-Deposition Treatment of ILD Layer for a Lower Dielectric Constant and Improved Mechanical Properties

REQUEST TO CORRECT FILING RECEIPT

Dear Sir:

On the copy of the enclosed Filing Receipt, there is an error in the list of Applicants. The second Applicant's residence is incorrect. Mr. Ko's name and corrected residence reads as follows; Chung-Chi Ko, **Nantou**, Taiwan.

Please make the necessary change to correct the error on the Filing Receipt.

If there are any questions, please contact the undersigned attorney at (845) 452-5863. Thank you for your attention to this matter.

Respectfully Submitted,

Stephen B. Ackerman, Reg. No. 37,761



MAY 11 2004

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| APPL NO. | FILING OR 371 (c) DATE | ART UNIT | FIL FEE REC'D | ATTY. DOCKET NO | DRAWINGS | TOT CLMS | IND CLMS |
|------------|---------------------------|----------|---------------|-----------------|----------|----------|----------|
| 10/666,354 | 09/19/2003 | 1762 | 1494 | TS02-1079 | 6 | 52 | 5 |

CONFIRMATION NO. 8188

GEORGE O. SAILE
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FILING RECEIPT



OC000000012540478

Date Mailed: 05/06/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Hui-Lin Chang, Hsin-Chu, TAIWAN;
Chung-Chi Ko, ~~Hsin-Chu~~ TAIWAN; *Asan Chu*
Tien I. Bao, Hsin-Chu, TAIWAN;
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Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted: 05/05/2004

Projected Publication Date: 03/24/2005

Non-Publication Request: No

Early Publication Request: No

Title

Two step post-deposition treatment of ILD layer for a lower dielectric constant and improved mechanical properties

Preliminary Class

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Title 35, United States Code, Section 184
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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